List of Publications by Year in descending order

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#	Article	IF	CITATIONS
1	Effects of graphene oxide concentration on optical properties of ZnO/RGO nanocomposites and their application to photocurrent generation. Journal of Applied Physics, 2014, 116, .	2.5	132
2	Synthesis and characterization of ZnO NPs/reduced graphene oxide nanocomposite prepared in gelatin medium as highly efficient photo-degradation of MB. Ceramics International, 2014, 40, 10217-10221.	4.8	131
3	One-pot sol–gel synthesis of reduced graphene oxide uniformly decorated zinc oxide nanoparticles in starch environment for highly efficient photodegradation of Methylene Blue. RSC Advances, 2015, 5, 21888-21896.	3.6	116
4	Enhancement of optical transmittance and electrical resistivity of post-annealed ITO thin films RF sputtered on Si. Applied Surface Science, 2018, 443, 544-547.	6.1	80
5	Crystalline quality assessment, photocurrent response and optical properties of reduced graphene oxide uniformly decorated zinc oxide nanoparticles based on the graphene oxide concentration. RSC Advances, 2015, 5, 53117-53128.	3.6	40
6	Structural, optical and electrical characterization of ITO, ITO/Ag and ITO/Ni transparent conductive electrodes. Applied Surface Science, 2014, 288, 599-603.	6.1	33
7	High Thermal Gradient in Thermo-electrochemical Cells by Insertion of a Poly(Vinylidene Fluoride) Membrane. Scientific Reports, 2016, 6, 29328.	3.3	33
8	Investigation of the electrochemical behavior of indium nitride thin films by plasma-assisted reactive evaporation. RSC Advances, 2015, 5, 17325-17335.	3.6	27
9	High performance InGaN LEDs on Si (1 1 1) substrates grown by MOCVD. Journal Physics D: Applied Physics, 2010, 43, 354008.	2.8	25
10	Effect of nitridation surface treatment on silicon (1 1 1) substrate for the growth of high quality single-crystalline GaN hetero-epitaxy layer by MOCVD. Applied Surface Science, 2016, 362, 572-576.	6.1	25
11	Plasma-assisted hot filament chemical vapor deposition of AlN thin films on ZnO buffer layer: toward highly c-axis-oriented, uniform, insulative films. Applied Physics A: Materials Science and Processing, 2014, 117, 2217-2224.	2.3	24
12	Indium Tin Oxide Coated D-Shape Fiber as a Saturable Absorber for Generating a Dark Pulse Mode-Locked Laser*. Chinese Physics Letters, 2020, 37, 054202.	3.3	24
13	Indium tin oxide coated D-shape fiber as saturable absorber for passively Q-switched erbium-doped fiber laser. Optics and Laser Technology, 2020, 124, 105998.	4.6	23
14	Effect of annealing on structural, optical, and electrical properties of nickel (Ni)/indium tin oxide (ITO) nanostructures prepared by RF magnetron sputtering. Superlattices and Microstructures, 2014, 70, 82-90.	3.1	22
15	Ammonia flux tailoring on the quality of AlN epilayers grown by pulsed atomic-layer epitaxy techniques on (0 0 0 1)-oriented sapphire substrates <i>via</i> MOCVD. CrystEngComm, 2019, 21, 2009-2017.	2.6	21
16	Effect of low NH3 flux towards high quality semi-polar (11-22) GaN on m-plane sapphire via MOCVD. Superlattices and Microstructures, 2018, 117, 207-214.	3.1	20
17	Structural ordering, morphology and optical properties of amorphous Al In1â ^{-,} N thin films grown by plasma-assisted dual source reactive evaporation. Journal of Alloys and Compounds, 2015, 632, 741-747.	5.5	17
18	In-situ tuning of Sn doped In2O3 (ITO) films properties by controlling deposition Argon/Oxygen flow. Applied Surface Science, 2019, 479, 1220-1225.	6.1	17

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19	Poly(3-hexylthiophene-2,5-diyl) regioregular (P3HT) thin film as saturable absorber for passively Q-switched and mode-locked Erbium-doped fiber laser. Optical Fiber Technology, 2020, 54, 102073.	2.7	17
20	Correlation between indium content in monolithic InGaN/GaN multi quantum well structures on photoelectrochemical activity for water splitting. Journal of Alloys and Compounds, 2017, 706, 629-636.	5.5	16
21	The effect of sputtering pressure on structural, optical and electrical properties of indium tin oxide nanocolumns prepared by radio frequency (RF) magnetron sputtering. Superlattices and Microstructures, 2014, 72, 140-147.	3.1	15
22	Positioning of periodic AlN/GaN multilayers: Effect on crystalline quality of a-plane GaN. Materials Science in Semiconductor Processing, 2020, 105, 104700.	4.0	15
23	Mode-locked erbium-doped fiber laser via evanescent field interaction with indium tin oxide. Optical Fiber Technology, 2020, 55, 102124.	2.7	15
24	Embedded AlN/GaN multi-layer for enhanced crystal quality and surface morphology of semi-polar (11-22) GaN on m-plane sapphire. Materials Science in Semiconductor Processing, 2018, 86, 1-7.	4.0	14
25	Non-Polar Gallium Nitride for Photodetection Applications: A Systematic Review. Coatings, 2022, 12, 275.	2.6	13
26	Improved optoelectronics properties of ITO-based transparent conductive electrodes with the insertion of Ag/Ni under-layer. Applied Surface Science, 2014, 315, 387-391.	6.1	12
27	Observation of saturation transfer characteristics in solution processed vertical organic field-effect transistors (VOFETs) with high leakage current. Current Applied Physics, 2018, 18, 1415-1421.	2.4	12
28	Crystal quality and surface structure tuning of semi-polar (11–22) GaN on m-plane sapphire via in-situ multiple ammonia treatment. Thin Solid Films, 2020, 697, 137817.	1.8	12
29	Optimization of poly(vinylidene fluoride) membranes for enhanced power density of thermally driven electrochemical cells. Journal of Materials Science, 2017, 52, 10353-10363.	3.7	11
30	Standard pressure deposition of crack-free AlN buffer layer grown on c-plane sapphire by PALE technique via MOCVD. Superlattices and Microstructures, 2018, 120, 319-326.	3.1	10
31	The optimization of n-type and p-type m-plane GaN grown on m-plane sapphire substrate by metal organic chemical vapor deposition. Materials Science in Semiconductor Processing, 2021, 131, 105836.	4.0	10
32	Nanocolumnar zinc oxide as a transparent conductive oxide film for a blue InGaN-based light emitting diode. Ceramics International, 2015, 41, 913-920.	4.8	9
33	High figure of merit of the post-annealed Ti/Al/ITO transparent conductive contacts sputter deposited on n-GaN. Journal of Alloys and Compounds, 2016, 681, 186-190.	5.5	9
34	Impact of a Strained Periodic Multilayer on the Surface and Crystal Quality of a Semipolar (11–22) GaN Template. Crystal Growth and Design, 2019, 19, 6092-6099. Growth of semi-polar complements and semiples and semiplate of semipolar (1988/Math/Math/Math/Math/Math/Math/M	3.0	9
35	altimg="si1.svg"> <mml:mrow><mml:mrow><mml:mo stretchy="true">(<mml:mrow><mml:mn>11</mml:mn><mml:mrow><mml:mover) 0.784<="" 1="" etqq1="" td="" tj=""><td>314 rgBT</td><td>/Oyerlock 10</td></mml:mover)></mml:mrow></mml:mrow></mml:mo </mml:mrow></mml:mrow>	314 rgBT	/Oyerlock 10
36	In-Situ Multiple Ammonia Treatment (I-SMAT) method. Vacuum, 2020, 174, 109208. Impact of crystallinity towards the performance of semi-polar (11–22) GaN UV photodetector. Materials Letters, 2021, 286, 129244.	2.6	9

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37	Effect of using two-step thermal annealing with different ambient gas on Mg activation and crystalline quality in GaN. Superlattices and Microstructures, 2015, 82, 592-598.	3.1	8
38	Effects of pulse cycle number on the quality of pulsed atomic-layer epitaxy AlN films grown via metal organic chemical vapor deposition. Japanese Journal of Applied Physics, 2019, 58, SC1037.	1.5	8
39	Agglomeration enhancement of AlN surface diffusion fluxes on a (0 0 0 1)-sapphire substrate grown by pulsed atomic-layer epitaxy techniques <i>via</i> MOCVD. CrystEngComm, 2020, 22, 3309-3321.	2.6	7
40	Growth of InGaN-based laser diode structure on silicon (111) substrate. Journal of Physics: Conference Series, 2009, 152, 012007.	0.4	6
41	Effect of Al0.06Ga0.94N/GaN Strained-Layer Superlattices Cladding Underlayer to InGaN-Based Multi-Quantum Well Grown on Si(111) Substrate with AlN/GaN Intermediate Layer. Japanese Journal of Applied Physics, 2010, 49, 021002.	1.5	6
42	Thermally Resistive Electrospun Composite Membranes for Lowâ€Grade Thermal Energy Harvesting. Macromolecular Materials and Engineering, 2018, 303, 1700482.	3.6	6
43	Solution-Processable Vertical Organic Light-Emitting Transistors (VOLETs) with Directly Deposited Silver Nanowires Intermediate Source Electrode. Journal of Nanoscience and Nanotechnology, 2019, 19, 6995-7003.	0.9	6
44	PEDOT:PSS Thin Film as Transparent Electrode in ITO-Free Organic Solar Cell. Advanced Materials Research, 2012, 501, 252-256.	0.3	5
45	First-principles calculation of structural, optoelectronic properties of the cubic Al Ga In1 N quaternary alloys matching on AlN substrate, within modified Becke–Johnson (mBJ) exchange potential. Optik, 2016, 127, 11577-11587.	2.9	5
46	Metal organic chemical vapor deposition of m-plane GaN epi-layer using a three-step approach towards enhanced surface morphology. Thin Solid Films, 2018, 667, 48-54.	1.8	5
47	MEH-PPV organic material as saturable absorber for Q-switching and mode-locking applications. Journal of Modern Optics, 2020, 67, 746-753.	1.3	5
48	Improved performance of InGaN/GaN LED by optimizing the properties of the bulk and interface of ITO on p-GaN. Applied Surface Science, 2021, 540, 148406.	6.1	5
49	The effect of Multi Quantum Well growth regime transition on MQW/p-GaN structure and light emitting diode (LED) performance. Materials Science in Semiconductor Processing, 2021, 121, 105431.	4.0	5
50	Diminishing the Induced Strain and Oxygen Incorporation on Aluminium Nitride Films Deposited Using Pulsed Atomic-Layer Epitaxy Techniques at Standard Pressure MOCVD. Journal of Electronic Materials, 2021, 50, 2313-2322.	2.2	5
51	Compositional and Structural Characterization of Heterostructure InGaN-Based Light-Emitting Diode by High Resolution X-Ray Diffraction. Advanced Materials Research, 0, 620, 22-27.	0.3	4
52	InGaN-based multi-quantum well light-emitting diode structure with the insertion of superlattices under-layer. Superlattices and Microstructures, 2013, 60, 201-207.	3.1	4
53	Effect of indium pre-flow on wavelength shift and crystal structure of deep green light emitting diodes. Optical Materials Express, 2021, 11, 926.	3.0	4
54	Study of Annealed Nickel (Ni)/Indium Tin Oxide (ITO) Nanostructures Prepared by RF Magnetron Sputtering. Advanced Materials Research, 2013, 832, 695-699.	0.3	3

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55	Effects of Pressure Dependence on Nanocolumnar Zinc Oxide Deposited by RF Magnetron Sputtering. Advanced Materials Research, 2013, 832, 787-791.	0.3	3
56	Nanostructured Al-doped ZnO-based gas sensor prepared using sol-gel spin-coating method. , 2014, , .		3
57	Post-Annealing Effects on ITO Thin Films RF Sputtered at Different Thicknesses on Si and Glass. Advanced Materials Research, 0, 925, 411-415.	0.3	3
58	Effect of thermal interaction between bulk GaN substrates and corral sapphire on blue light emission InGaN/GaN multi-quantum wells by MOCVD. Superlattices and Microstructures, 2018, 119, 157-165.	3.1	3
59	Impact of sandwiched strain periodic multilayer AlN/GaN on strain and crystalline quality of a-plane GaN. Scientific Reports, 2021, 11, 9724.	3.3	3
60	Magnesium doped semipolar (11–22) p-type gallium nitride: Impact of dopant concentration variants towards grain size distributions and crystalline quality. Thin Solid Films, 2022, 741, 139003.	1.8	3
61	Structural and Optical Properties of Nickel-Doped Zinc Oxide Thin Film on Nickel Seed Layer Deposited by RF Magnetron Sputtering Technique. Advanced Materials Research, 0, 895, 3-7.	0.3	2
62	Development of atmospheric pressure plasma needle jet for sterilization applications. AIP Conference Proceedings, 2017, , .	0.4	2
63	The crystallographic quality and band-edge transition of as-deposited PALE AIN films via metal organic chemical vapor deposition. Journal of Materials Science: Materials in Electronics, 2021, 32, 3211-3221.	2.2	2
64	Enhanced indium adsorption and surface evolution of semi-polar (11–22) LED via a strain periodic alternating superlattice (SPAS-L). Materials Today Communications, 2021, 27, 102441.	1.9	2
65	Effect of Flux Rate Variation at Fixed V/III Ratio on Semi-Polar (112Â ⁻ 2) GaN: Crystal Quality and Surface Morphology Study. Crystals, 2022, 12, 247.	2.2	2
66	Effect of AlGaNâ^•GaN Strained-Layer Superlattices Underlayer to InGaN-based Multi-Quantum Wells Grown on Si(111) Substrate by MOCVD. , 2011, , .		1
67	Electrical and Optical Characterization of Mg Doping in GaN. Advanced Materials Research, 0, 620, 453-457.	0.3	1
68	Effect of Substrate Temperature on Structural and Morphological Properties of Indium Tin Oxide Nanocolumns Using RF Magnetron Sputtering. Advanced Materials Research, 2014, 895, 12-16.	0.3	1
69	Structural and Optical Properties of Nickel (Ni)/indium Tin Oxide (ITO) Thin-Films Deposited by RF Magnetron Sputtering. Advanced Materials Research, 2014, 895, 181-185.	0.3	1
70	Characterization of ITO/Ag and ITO/Ni Bi-Layer Transparent Conductive Electrodes. Advanced Materials Research, 0, 1024, 75-78.	0.3	1
71	Fabrications of Nanocomposite Gold-Polymer Metamaterials Consisting of Periodic Microcavities with Tunable Optical Properties. Optik, 2017, 150, 54-61.	2.9	1
72	Effect of working power and pressure on plasma properties during the deposition of TiN films in reactive magnetron sputtering plasma measured using Langmuir probe measurement. Journal of Physics: Conference Series, 2018, 995, 012068.	0.4	1

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73	Fabrication of In _x Ga _{1-x} N/GaN Multi-Quantum well Structure for Green Light Emitting Diode on Patterned Sapphire Substrate by Metal Organic Chemical Vapour Deposition. Solid State Phenomena, 2019, 290, 147-152.	0.3	1
74	Improving Material Quality of Polycrystalline GaN by Manipulating the Etching Time of a Porous AlN Template. Journal of Electronic Materials, 2019, 48, 3547-3553.	2.2	1
75	Alq 3 saturable absorber for generating Qâ€switched pulses in erbiumâ€doped fiber laser. Microwave and Optical Technology Letters, 2020, 62, 1028-1032.	1.4	1
76	Influence of post-ammonia annealing temperature on e-beam evaporation deposited GaN layer on patterned sapphire substrate. Superlattices and Microstructures, 2020, 148, 106722.	3.1	1
77	Disilane doping of semi-polar (11-22) n-GaN: The impact of terrace-like evolution toward the enhancement of the electrical properties. Thin Solid Films, 2021, 720, 138489.	1.8	1
78	Effect of nucleation layer thickness on reducing dislocation density in AlN layer for AlGaN-based UVC LED. Microelectronics International, 2021, 38, 113-118.	0.6	1
79	Improvement of c-axis (002) AlN crystal plane by temperature assisted HiPIMS technique. Microelectronics International, 2021, 38, 86-92.	0.6	1
80	Luminescence and Crystalline Properties of InGaN-based LED on Si Substrate with AlN/GaN Superlattice Structure. Journal of Physical Science, 2021, 32, 1-11.	0.9	1
81	InGaN-based blue LED grown on Si(111) substrate. , 2011, , .		Ο
82	Structural properties of InGaN-based light-emitting diode epitaxial growth on Si (111) with AlN/InGaN buffer layer. , 2012, , .		0
83	Electronic properties and electrical characteristics of modified PEDOT:PSS as a buffer layer in organic solar cell. , 2012, , .		Ο
84	Influence of Substrate Temperature on Morphological and Electrical Properties of Indium Tin Oxide Nanocolumns Prepared by RF Magnetron Sputtering. Advanced Materials Research, 2013, 832, 281-285.	0.3	0
85	Effects of Oxygen Gas Composition on Nanocolumnar Zinc Oxide Properties Deposited by RF Magnetron Sputtering. Advanced Materials Research, 0, 832, 783-786.	0.3	Ο
86	A Study on the Seebeck Effect of 3,4,9,10-Perylenetetracarboxylic Dianhydride (PTCDA) as a Novel N-Type Material in a Thermoelectric Device. Advanced Materials Research, 2013, 667, 165-171.	0.3	0
87	Influence of RF Magnetron Sputtering Pressure on the Structural, Optical, and Morphological Properties of Indium Tin Oxide Nanocolumns. Advanced Materials Research, 2013, 832, 276-280.	0.3	Ο
88	Effect of Annealing on Surface of Nickel (Ni)/Indium Tin Oxide (ITO) Nanostructures Measured by Atomic Force Microscopy (AFM). Advanced Materials Research, 2013, 832, 51-55.	0.3	0
89	Numerical estimation of self-sputtering effect in ionized physical vapor deposition system. , 2014, , .		0
90	Effects of Growth Temperature on the Structural Properties of Zinc Oxide Nanograins Deposited by RF Magnetron Sputtering. Advanced Materials Research, 2014, 895, 500-504.	0.3	0

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91	Effect of Sn dopant concentration on structural and electrical properties of ZnO nanostructures based methane gas sensor. , 2015, , .		0
92	Modeling and simulation of metal organic halide vapor phase epitaxy (MOHVPE) growth chamber. Microsystem Technologies, 2015, 21, 309-318.	2.0	0
93	Fabrication of nanostructured Al-doped ZnO thin film for methane sensing applications. AIP Conference Proceedings, 2016, , .	0.4	0
94	Nitrogen emission in reactive magnetron sputtering plasmas during the deposition of titanium nitride thin film. AIP Conference Proceedings, 2017, , .	0.4	0
95	Synthesis and characterization of InN nanocrystals on glass substrate by plasma assisted reactive evaporation. AIP Conference Proceedings, 2017, , .	0.4	0
96	Surface and optical characteristics of polycrystalline GaN layer with different pores profile of porous GaAs/GaAs substrate. Materials Research Express, 2019, 6, 085906.	1.6	0
97	Effect of the Bias Voltage on the Polycrystalline a-axis Oriented AlN Thin Films by RF Sputtering. , 2019, , .		0
98	Electronic surface, optical and electrical properties of p – GaN activated via in-situ MOCVD and ex-situ thermal annealing in InGaN/GaN LED. Materials Science in Semiconductor Processing, 2020, 106, 104757.	4.0	0
99	Structural and mechanical properties of a-axis AlN thin films growth using reactive RF magnetron sputtering plasma. Microelectronics International, 2021, 38, 99-104.	0.6	0
100	Anodization voltage effect on physical properties of anodic TiO2 nanotube arrays film. AIP Conference Proceedings, 2020, , .	0.4	0